In re Appln. of Takayuki HISAKA Application No. Unassigned

ABSTRACT AMENDMENTS

Replace the Abstract with:

A semiconductor device includes a semiconductor substrate $+\theta$, a channel layer 7, a Schottky layer $+\theta$, a first layer $+\theta$ having a narrower band gap than the Schottky layer, a second layer ++ having band discontinuity with the Schottky layer, a gate electrode ++, an n+ layer 4, a source electrode ++, and a drain electrode ++. The first and second layers are inserted ++ within the Schottky layer, and the second layer is disposed on the first layer.